

Elite Etch Cu 7100 Specifications

| Etcher Unit | Height: 300 mm (13 in) |
|---------------------------------|---|
| | Width: 190 mm (7.5 in) |
| | Depth: 305 mm (12 in) |
| Bottle Assembly | Height: 254 mm (10 in) |
| | Width: 280 mm (11 in) |
| | Depth: 127 mm (5 in) |
| Weight | Approx. 16 kg (35 lb) |
| Power Source | 90 to 250 VAC, 50 to 60 Hz (4 amp) |
| Acid temp. range | 10° to 250° C |
| Acid temp. set point | 1°C±1% of setting |
| Etch cavity (up to) | 22 mm x 22 mm (30 mm diagonal) |
| Choice of Acids | fuming nitric acids, mixed fuming nitric and sulfuric acids, or fuming/concentrated sulfuric acid |
| Acid Mix Ratios | (nitric to sulfuric ratios) 9:1, 6:1, 5:1, 4:1, 7:2, 3:1, 5:2, 2:1, 3:2, 1:1, 1:2, 1:3, 1:4, 1:5 |
| Post Etch Rinse Options | sulfuric acids, fuming nitric acids, mixed acids, or no rinse |
| Etch Times | 1 to 2,400 seconds in 1 second increments (1 seconds to 40 minutes) dynamic (real time) adjustments of etch time |
| Etchant Volume Selection | 1 to 8 ml per minute - for all acids & acid mixes |
| Etch Delivery Functions | pulsed or Reciprocal Etch Acid Pulse (REAP) for lower acid consumption |
| Operator Program Storage | 100 programs stored to nonvolatile memory |
| Warranty | most comprehensive and inclusive warranty in industry (ask for full details) |
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